

N-Channel Enhancement MOSFET

Features

- Drain-Source Breakdown Voltage V_{DSS} -20 V
- Drain-Source On-Resistance $R_{DS(ON)}82m\Omega, \text{ at V}_{GS}=10\text{V}, \text{ I}_{D}=2.6\text{A}$ $R_{DS(ON)}96m\Omega, \text{ at V}_{GS}=4.5\text{V}, \text{ I}_{D}=2.1\text{A}$
- Continuous Drain Current at T_C=25°C I_D = 2.6A
- Advanced high cell density Trench Technology
- RoHS Compliance & Halogen Free

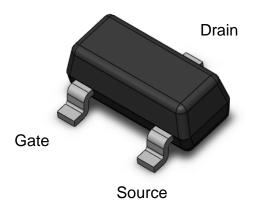
Applications

- Power Management
- Lithium Ion Battery

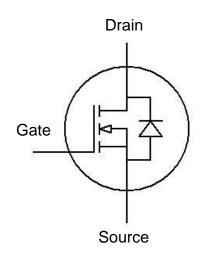
Description

The CTL0266NS-R3 is the N-Channel logic enhancement mode power field effect transistors are produced using high cell density, DMOS trench technology. This high density process is especially tailored to minimize on-state resistance. These devices are particularly suited for low voltage application such as cellular phone and notebook computer power management and other battery powered circuits where high-side switching and low in-line power loss are needed in a very small outline surface mount package.

Package Outline



Schematic





N-Channel Enhancement MOSFET

Absolute Maximum Rating at 25°C

Symbol	Parameters	Test Conditions	Min	Notes
VDS	Drain-Source Voltage	60	V	
Vgs	Gate-Source Voltage	±20	V	
lσ	Continuous Drain Current	2.6	Α	1
Ірм	Pulsed Drain Current	10	Α	1
PD	Total Power Dissipation	1.04	W	2
Тѕтс	Storage Temperature Range	-55 to 150	°C	
TJ	Operating Junction Temperature Range	-55 to 150	°C	

Thermal Characteristics

Symbol	Parameters	Test Conditions	Min	Тур	Max	Units	Notes
R⊕JA4	Thermal Resistance			110		00 444	4.4
К ӨЈА4	Junction-Ambient (t=10s)			110		°C W	1,4



N-Channel Enhancement MOSFET

Electrical Characteristics $T_A = 25$ °C (unless otherwise specified)

Static Characteristics

Symbol	Parameters	Test Conditions	Min	Тур	Max	Units	Notes
Bvdss	Drain-Source Breakdown Voltage	Vgs= 0V, ID= -250µA	60	-	-	V	
IDSS	Drain-Source Leakage Current	VDS = 60V, VGS = 0V	-	-	-1	μА	
lgss	Gate-Source Leakage Current	Vgs = ±20V, Vps = 0V	-	-	±100	nA	

On Characteristics

Symbol	Parameters	Test Conditions	Min	Тур	Max	Units	Notes
D	Drain-Source On-Resistance	$V_{GS} = 10V, I_D = 2.6A$	-	82	100	mΩ	2
Rds(ON)	Drain-Source On-Resistance	Vgs = 4.5V, ID = 2.1A	-	96	130	mΩ	3
VGS(th)	Gate-Source Threshold Voltage	V _G S = V _D S, I I _D =-250μA	1.0		3.0	V	3

Dynamic Characteristics

Symbol	Parameters	Test Conditions	Min	Тур	Max	Units	Notes
Ciss	Input Capacitance	Vgs =0V,	-	350	-		
Coss	Output Capacitance	Vps =30V	-	40	-	pF	
Crss	Reverse Transfer Capacitance	f=1MHz	-	12	-		

Switching Characteristics

Symbol	Parameters	Test Conditions	Min	Тур	Max	Units	Notes
T _{D(ON)}	Turn-On Delay Time	V _{DS} = 20V,	-	10	-		
TR	Rise Time	$V_{GS} = 10V$,	-	11	-		
T _D (OFF)	Turn-Off Delay Time	$R_G = 1\Omega$,	-	29	-	ns	
TF	Fall Time	$R_L=20\Omega$,	-	3	-		
Q _G	Total Gate Charge	V _{DS} = 30V ,	-	6.5	-		
Qgs	Gate-Source Charge	V _{GS} = 4.5V,	-	2.2	-	nC	
Q _{GD}	Gate-Drain Charge	I _D = 2.6A	-	2.7	-		



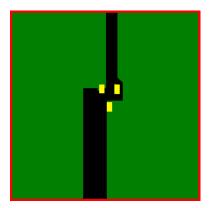
N-Channel Enhancement MOSFET

Drain-Source Diode Characteristics

Symbol	Parameters	Test Conditions	Min	Тур	Max	Units	Notes
VsD	Body Diode Forward Voltage	Vgs = 0V, ID = 1A	-	0.8	1.2	V	
Isp	Body Diode Continuous Current		-	-	2.1	Α	1

Note:

- 1. The power dissipation is limited by 150°C junction temperature.
- 2. Device mounted on a glass-epoxy board



FR-4

25.4 × 25.4 mm.

2 Oz Copper

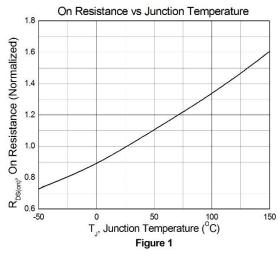
Test Board

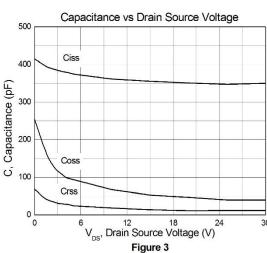
- 3. The data tested by pulsed , pulse width $\leq 300 \mu s$, duty cycle $\leq 2\%$
- 4. Thermal Resistance follow JESD51-3.

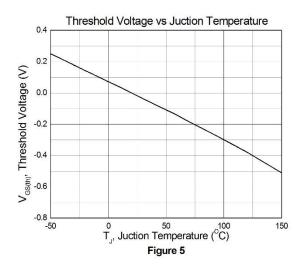


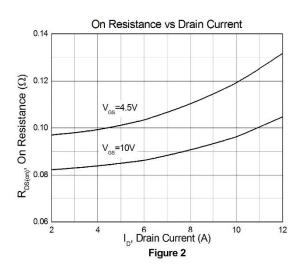
N-Channel Enhancement MOSFET

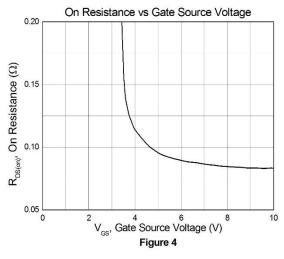
Typical Characteristic Curves

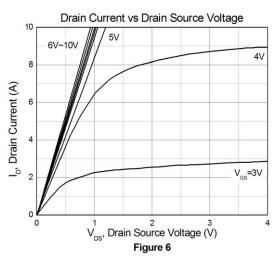






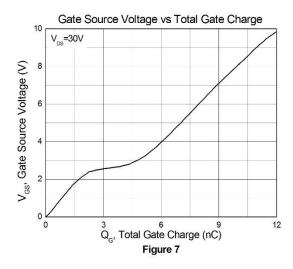


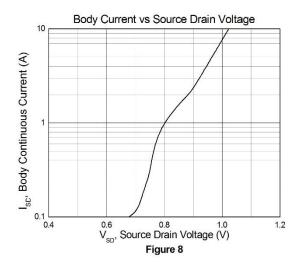






N-Channel Enhancement MOSFET









N-Channel Enhancement MOSFET

Test Circuits & Waveforms

Figure 12: Gate Charge Test Circuit

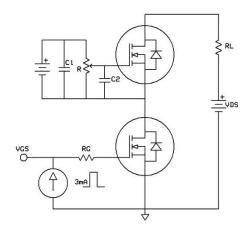


Figure 14: Switching Time Test Circuit

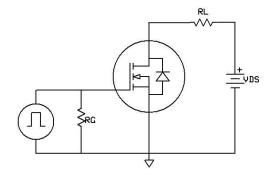


Figure 13: Gate Charge Waveform

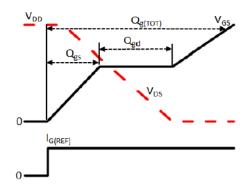
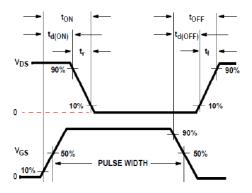


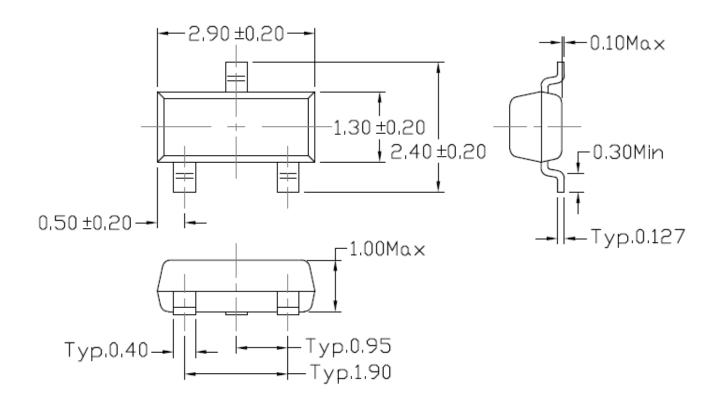
Figure 15: Switching Time Waveform



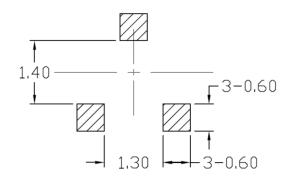


N-Channel Enhancement MOSFET

Package Dimension (SOT-23)



Recommended pad layout for surface mount leadform

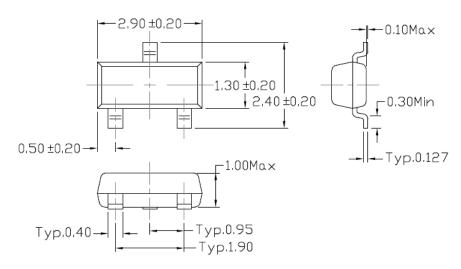




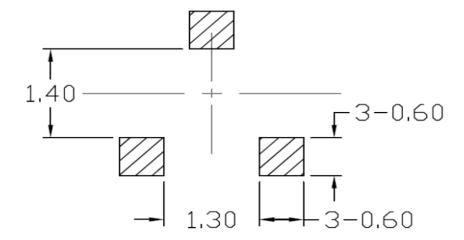


N-Channel Enhancement MOSFET

Package Dimension Dimensions in mm unless otherwise stated

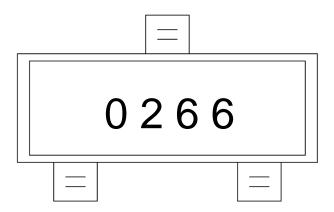


Recommended pad layout for surface mount leadform



N-Channel Enhancement MOSFET

Marking Information



0266: Device Number

Ordering Information

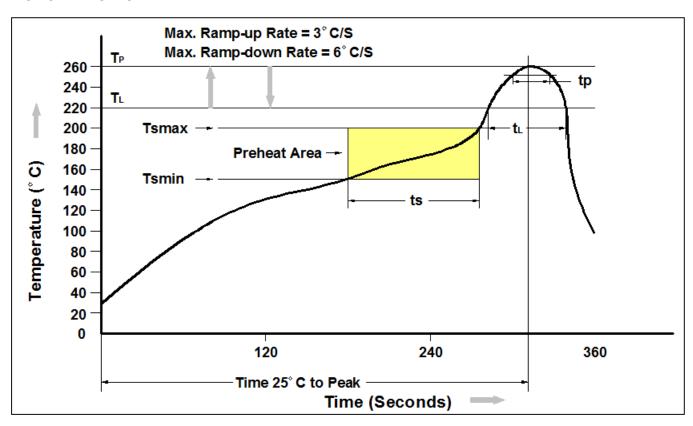
Part Number	Description	Quantity
CTL0266NS-R3	SOT-23 Reel	3000 pcs





N-Channel Enhancement MOSFET

Reflow Profile



Profile Feature	Pb-Free Assembly Profile
Temperature Min. (Tsmin)	150°C
Temperature Max. (Tsmax)	200°C
Time (ts) from (Tsmin to Tsmax)	60-120 seconds
Ramp-up Rate (t∟ to t⊳)	3°C/second max.
Liquidous Temperature (T _L)	217°C
Time (t _L) Maintained Above (T _L)	60 – 150 seconds
Peak Body Package Temperature	260°C +0°C / -5°C
Time (t _P) within 5°C of 260°C	30 seconds
Ramp-down Rate (T _P to T _L)	6°C/second max
Time 25°C to Peak Temperature	8 minutes max.



N-Channel Enhancement MOSFET

DISCLAIMER

CT MICRO RESERVES THE RIGHT TO MAKE CHANGES WITHOUT FURTHER NOTICE TO ANY PRODUCTS HEREIN TO IMPROVE RELIABILITY, FUNCTION OR DESIGN. CT MICRO DOES NOT ASSUME ANY LIABILITY ARISING OUT OF THE APPLICATION OR USE OF ANY PRODUCT OR CIRCUIT DESCRIBED HEREIN; NEITHER DOES IT CONVEY ANY LICENSE UNDER ITS PATENT RIGHTS, NOR THE RIGHTS OF OTHERS.

CT MICRO ARE NOT AUTHORIZED FOR USE AS CRITICAL COMPONENTS IN LIFE SUPPORT DEVICES OR SYSTEMS WITHOUT EXPRESS WRITTEN APPROVAL OF CT MICRO INTERNATIONAL CORPORATION.

- Life support devices or systems are devices or systems which, (a) are intended for surgical implant into the body, or (b) support or sustain life, or (c) whose failure to perform when properly used in accordance with instruction for use provided in the labelling, can be reasonably expected to result in significant injury to the user.
- A critical component is any component of a life support device or system whose failure to perform can be reasonably expected to cause the failure of the life support device or system, or to affect its safety or effectiveness.